Patent Claims

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- 1. A hydrophobic, pyrogenically produced silica, having a tamped density of 55 to 200 g/l.
- 2. The hydrophobic, pyrogenically produced silica according to claim 1 having a tamped density of 60 to 200 g/l.
- 5 3. The hydrophobic pyrogenically produced silica according to claim 1 which is hydrophobicized by reaction with a halogen-free silane.

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- 4. The hydrophobic, pyrogenically produced silica according to claim 4 wherein said silica has a chloride content of less than or equal to 100 ppm.
- A process for the production of the hydrophobic, pyrogenically produced silica as claimed in
 claim 1, comprising hydrophobizing pyrogenically produced silica and then compacting said silica.
 - 6. The process according to claim 5 wherein said compacting is by roller compactor.
 - 7. The process according to claim 5 wherein said compacting is by belt filter press.
 - 8. A hydrophobic, pyrogenically produced silica having been produced by the process of claim

15 5.

- 9. Use of the hydrophobic, pyrogenically produced silica as claimed in claim 1 for the production of dispersions.
- 10. A dispersion of a hydrophobic, pyrogenically produced silica produced by the process of claim 5.